

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant

: PAN et al.

Confirmation No: 4127

Appl. No. Filed

: 10/617,679 : July 14, 2003

Title

: METHOD OF POLISHING SEMICONDUCTOR COPPER

INTERCONNECT INTEGRATED WITH EXTREMELY LOW

DIELECTRIC CONSTANT MATERIAL

TC/A.U.

: 3723

Examiner

: H. Shakeri

Docket No.:

: PANW3002/REF

Customer No:

: 23364

<u>AMENDMENT</u>

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

This is in response to the Official Action of August 23, 2004, in connection with the above-identified application. This response is timely filed.

Please amend the application as follows:

Amendments to the claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 4 of this paper.